

Docket No.

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Application	n No.	Filing I	Date	Examin	er	Art Unit	
09/588,008		June 6, 2000		Hoa B. Tı	rinh	h 2814	
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Thomas J. D Ar Attorney Reg. N							
DICKSTEIN SH		N & OSHINSK	Y LLP				
2101 L Street N	100						

Washington, DC 20037-1526 (202) 828-2232



Docket No.: M4065.0210/P210 (PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Yang et al.

Application No.: 09/588,008

Application 140.. 09/ 388,008

Filed: June 6, 2000

For: IMPROVED MEMORY CELL CAPACITOR

STRUCTURE AND METHOD OF

FORMATION

#10 And B V13/02 Group Art Unit: 2814

Examiner: Vikki H. Trinh

AMENDMENT UNDER 37 CFR §1.116

ATTN: BOX AF

Commissioner for Patents Washington, DC 20231

Dear Sir:

This paper is in response to the Office Action dated June 4, 2002 finally rejecting claims 1-31, 97, and 98, please amend the above-captioned U.S. Patent application as follows:

In the Claims:

Please replace claims 1, 97, and 98 with amended claims 1, 97, and 98 below.

1. (amended) A capacitor for a semiltonductor device, said capacitor comprising:

a bottom conducting layer;

a dielectric layer formed over said bottom conducting layer; and

an annealed oxygen permeable top conducting layer formed over said dielectric

1499532 v1; W51_01!.DOC